

# Journal of MATERIALS RESEARCH

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# Journal of MATERIALS RESEARCH

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Cover: FIG. 3(a) - SEM image of a sintering-induced cracking gap in a nanocolloidal (NC) crystal, showing freestanding NC chains. [D. Zhang, Y-R Huang, Y. Xu, D. Lee, G. Feng: Comparing sintering and atomic layer deposition as methods to mechanically reinforce nanocolloidal crystals. p. 3717].

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